

October 3-4, 2010 - Paris - Espaces CAP 15 Centre International d'Affaires et de Congrès

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Given the more than positive experience of the *Symposium on Continuous Flow Reaction Technology for Industrial Applications* which was held in Madrid on October 12th 2009, Chimica Oggi/Chemistry Today has decided to organize a new edition this year on October 3-4, which are the days immediately before CPhI Worldwide.

The 2nd Symposium will be an ideal continuation of the first one and provide updating on the newest instructions, developments, and applications of this technology.

Moreover, on the basis of the feedback collected during the Symposium in Madrid, enhancements and new topics will be on schedule: equipment, auxiliary equipment, regulation/safety issues, design practice and PAT.

Just the two days before CPhI WW begins!!!

Look at the 1st Symposium's materials:

http://chemistry-today.teknoscienze.com/lp/madrid_symposium.html

